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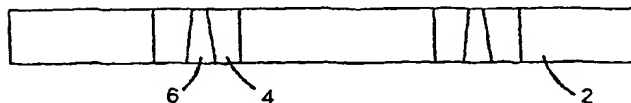
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(54) Title: METHOD OF MANUFACTURING A COMPONENT FOR DROPLET DEPOSITION APPARATUS



(57) Abstract: A nozzle plate component is manufactured by forming a layer of photoresist on a substrate and selectively exposing and removing material to define an array of distinct bodies. Nickel is then electroformed around the bodies to form a plate, with nozzles subsequently formed by ablation through the photoresist. The process can essentially be repeated to form a guard structure around each nozzle.

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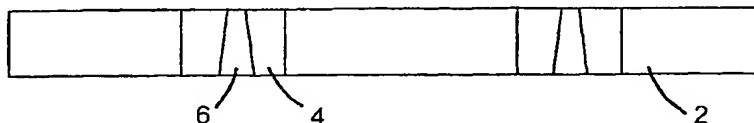
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